Please type a plus sign (+) inside this box \rightarrow [+]

N. K. K.

PTO/SB/08A (08-00)

Approved for use through 10/31/2002. OMB 0651-0031 t and Trademark Office: U.S. DEPARTMENT OF COMMERCE collection of information unless it contains a valid OMB control number.

	for form 1449A/PTO	. 01 1323,	13	DEMARK CITY	Complete if Known		
INEO	RMATION I	DISC		Application Number	09/732,928		
				Filing Date	December 11, 2000		
STAT	TEMENT BY	APP	LICANI	First Named Inventor	Nobuo SHIMAZU et al.		
	(use as many sheets	as necessi	ary)	Group Art Unit	Unknown		
				Examiner Name	Unknown		
Sheet	1	of	1	Attorney Docket Number	740107-136		

U.S. PATENT DOCUMENTS							
Examiner Initials	Cite No. ¹	U.S. Patent Document		Name of Patentee or Applicant of Cited	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
		Number	Kind Code ² (if known)	Document	WWI-DD-1111		
-3/H		5,831,272		Utsumi	11-03-1998		
	-						
							
			-				
	 						

					FC	REIGN PATENT DOCU	JMENTS		
Examiner Initials*	Cite No.1	Foreign Patent Document Kind Code ⁵				Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	т•
		Office ³	Number ⁴	(if known)		Applicant of Cited Bostanion	WHITE THE		
								,	
				OTHER P	RIOR .	ART – NON PATENT LITE	RATURE DOCUMENTS		
Examiner Initials	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.)., date, page(s), volume-issue number(s), publisher, city and/or country where published.						T ²	
J#	-	PRO	HIGH THROUGHPUT SUBMICRON LITHOGRAPHY WITH ELECTRON BEAM PROXIMITY PRINGING, H. BOHLEN ET AL., SOLID STATE TECHNOLOGY, SEPTEMBER 1984, PAGES 210-217						
JH		DIS	COVER	OF MIS	SINC	ON-BEAM PROXIM G LINK, TAKAO UT R 1999, PAGES 289	SUMI, J. VAC. SCI.	LITHOGRAPHY: TECHNOL. B 17(6),	
-									

Examiner Signature	land-1/m	Date Considered	7/6/03	

^{*}EXAMINED. Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹ Unique citation designation number. ² See attached Kinds of U.S. Patent Documents. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. ⁶ Applicant is to place a check mark here if English language Translation is attached.

¹Unique citation designation number. ² Applicant is to place a check mark here if English language Translation is attached.